

CPA/1752

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date October 3, 2002

In re the Application of

Masaru MITSUI et al.

Group Art Unit: 1752

Application No.: 09/509,472

Examiner: Y. Clarke

Filed: April 21, 2000

Docket No.: 105875

For: PHOTOMASK BLANK, PHOTOMASK, METHODS OF MANUFACTURING THE SAME AND
METHOD OF FORMING MICROPATTERN

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**LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION
OF TIME UNDER 37 C.F.R. §1.136(a) AND
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

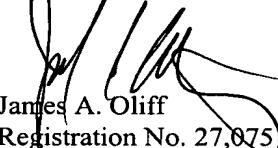
Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired July 3, 2002, an extension of time for a period of 3 months is hereby requested. Attached hereto is our Check No. 135121 in the amount of \$920 in payment for:

- Extension fee for response within first month pursuant to §1.136(a) (\$110.00)
 Extension fee for response within second month pursuant to §1.136(a) (\$400.00)
 Extension fee for response within third month pursuant to §1.136(a) (\$920.00)

The Director is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461. Two copies of this petition are enclosed.

Respectfully submitted,


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DEPOSIT ACCOUNT USE
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